

Application No.: 10/645,552
Amendment dated May 20, 2005
Reply to Office action dated February 24, 2005

Docket No.: M4065.0953/P953

THE CLAIMS

Listing of Claims:

1. (Previously presented) A pixel cell comprising:

a photo-conversion device that generates charge;

a gate controlled charge storage region that stores the charge under

control of a control gate, and

a first transistor having its gate between the photo-conversion

device and the charge storage region for transferring charge from the photo-

conversion device to the charge storage region.
2. (Original) The pixel cell of claim 1, wherein the charge storage
region is part of a buried channel MOS capacitor.
3. (Original) The pixel cell of claim 1, wherein the charge storage
region is below a surface of the substrate.
4. (Original) The pixel cell of claim 1, wherein the charge storage
region comprises:

a doped region of a second conductivity type; and

a doped surface layer of a first conductivity type over and in
contact with the doped region of a second conductivity type, the control gate
being over the doped surface layer.

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5. (Original) The pixel cell of claim 1, wherein the control gate comprises polysilicon doped with a first conductivity type dopant.
6. (Original) The pixel cell of claim 1, wherein the first transistor is a shutter transistor for determining an integration time for the pixel cell.
7. (Previously presented) A pixel cell comprising:
 - a photo-conversion device that generates charge;
 - a gate controlled charge storage region that stores the charge under control of a control gate,
 - a first transistor having its gate between the photo-conversion device and the charge storage region for transferring charge from the photo-conversion device to the charge storage region;
 - a sensing node; and
 - a second transistor having its gate between the charge storage region and the sensing node.
8. (Original) The pixel cell of claim 7, wherein the sensing node is a floating diffusion region.
9. (Original) The pixel cell of claim 7, wherein the control gate at least partially overlaps the first and second transistor gates.
10. (Original) The pixel cell of claim 1, wherein the photo-conversion device is a pinned photodiode.

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11. (Previously presented) A pixel cell comprising:

- a photo-conversion device that generates charge;
- a gate controlled charge storage region that stores the charge under control of a control gate, wherein the charge storage region comprises a doped region of a second conductivity type and a doped surface layer of a first conductivity type over and in contact with the doped region of a second conductivity type, and wherein the control gate is over the doped surface layer; and
- a first transistor having its gate between the photo-conversion device and the charge storage region for transferring charge from the photo-conversion device to the charge storage region.

12. (Original) The pixel cell of claim 11, wherein the charge storage region is part of a buried channel metal oxide semiconductor (MOS) capacitor.

13. (Previously presented) A pixel cell comprising:

- a photo-conversion device that generates charge;
- a gate controlled charge storage region that stores the charge under control of a control gate, wherein the charge storage region comprises a doped region of a second conductivity type and a doped surface layer of a first conductivity type over and in contact with the doped region of a second

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conductivity type, and wherein the control gate is over the doped surface layer;

a first transistor having its gate between the photo-conversion device and the charge storage region for transferring charge from the photo-conversion device to the charge storage region;

a sensing node; and

a second transistor having its gate between the charge storage region and the sensing node.

14. (Original) The pixel cell of claim 13, wherein the control gate overlaps the first and second transistor gates.

15-45 (Canceled).